

Nano and microlayers against material deterioration in aggressive environment

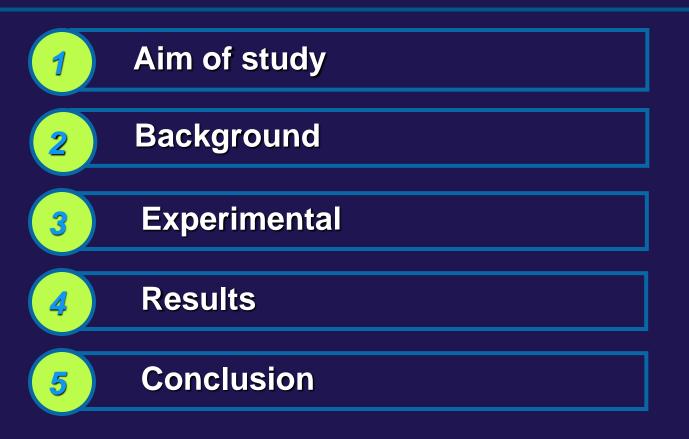
Talah Abohalkuma

Supervisor: Dr. Telegdi Lászlóné

Material Science and Technology PhD School of Óbuda University









Aim of study

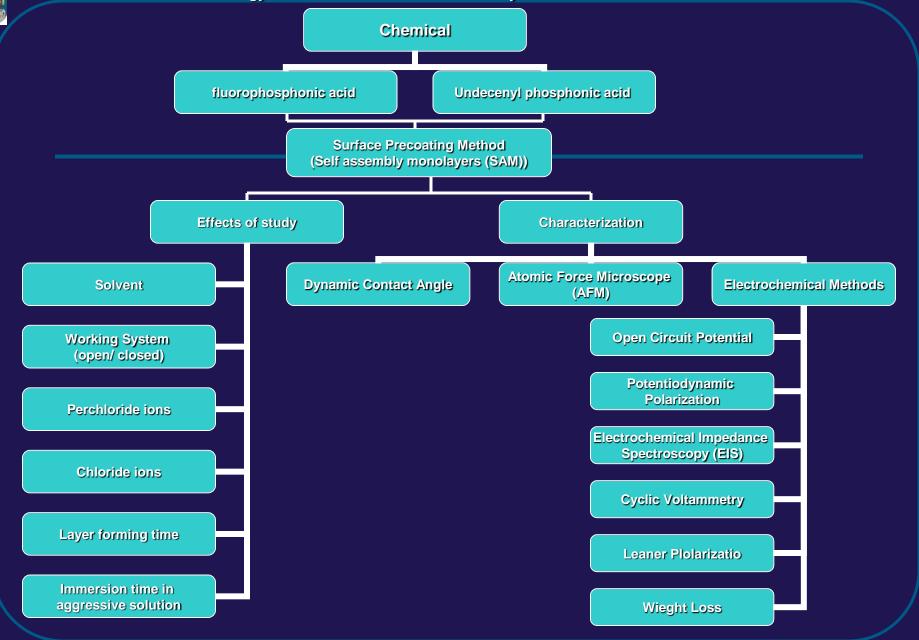
>Study of

- formation of self assembled molecular layers (SAM) on carbon steel and aluminum.
- influence of different variables (solvent, oxide layer, working system (open or closed), temperature,pH, chloride ions, perchloride) on the protective layer formation.

Characterization of the formed layers

- Contact angle measurement (presence of the layer)
- Atomic force microscopy (morphology of the layer)
- Electrochemical measurements: cyclic voltammetry (compactness of the layer), potentiodynamic polarization techniques, and electrochemical impedance spectroscopy (anticorrosion activity).

Material Science and Technology PhD School of Obuda University





Fulfillment of the sixth semester

Characterization of the formed layers by:

- Electrochemical Impedance Spectroscopy (EIS)
- Atomic force microscopy (AFM)

Study the effect of:

- Perchloride ions
- Time of layer formation
- Time of immersion in aggressive solution



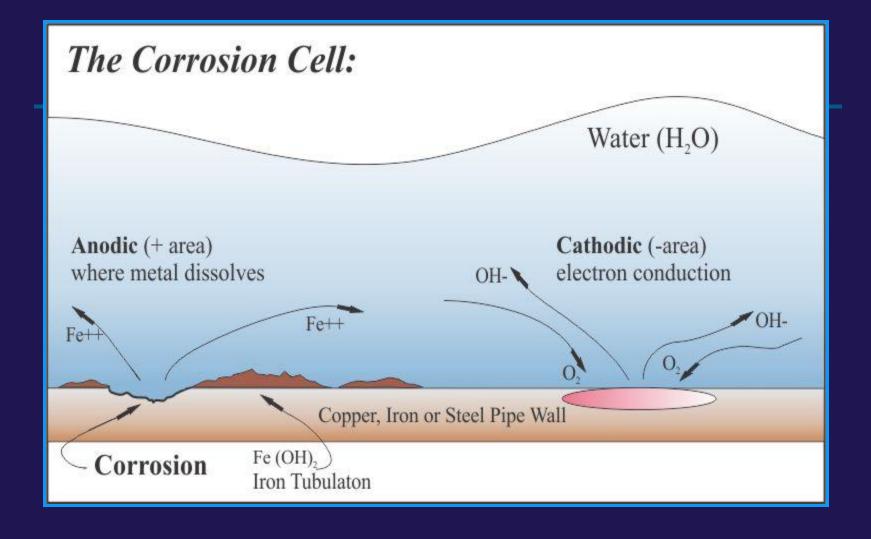
Publication on the sixth semesters

- A presentation "Special phosphonic acid nanolayers for controlling corrosion processes" Chemical Engineering day, 21- 23 April 2015, Veszprém,- Hungary
- A journal publication "Corrosion protection of carbon steel by special phosphonic acid nanolayers" Materials and Corrosion. (IF 2.3)
- A journal publication (in review) " Corrosion processes controled by phosphonic acid nano- layers" Periodica Polytechnica Chemical Engineering. (IF 0.3)



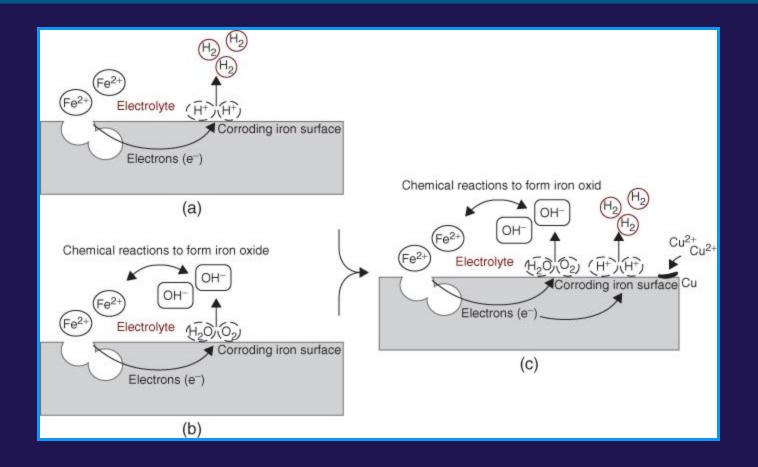








≻Corrosion process

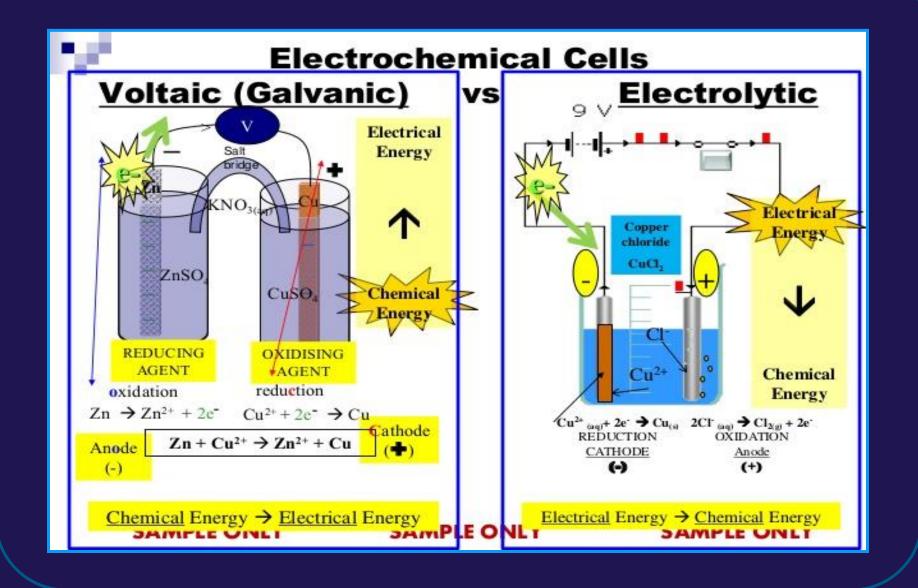










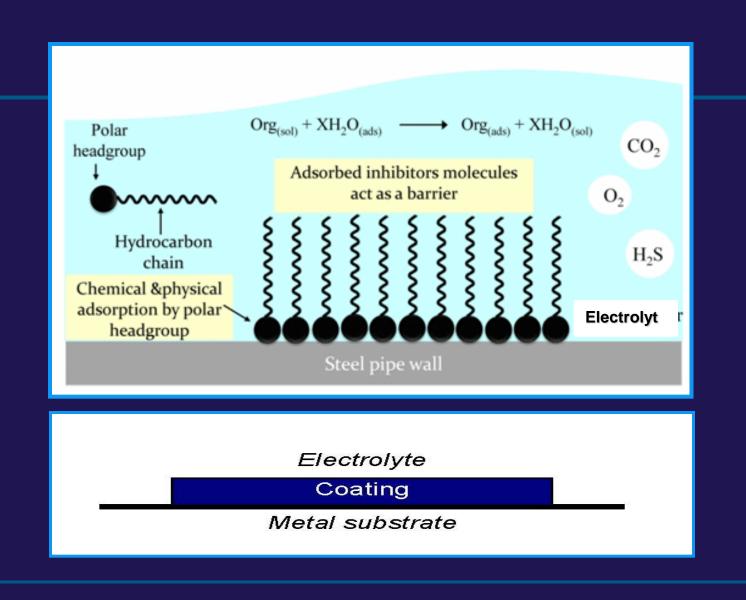




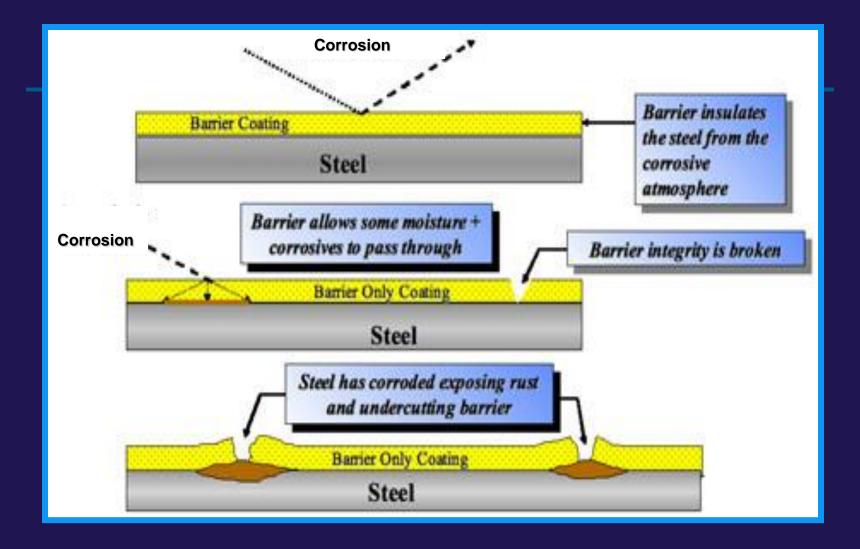
Methods of corrosion control





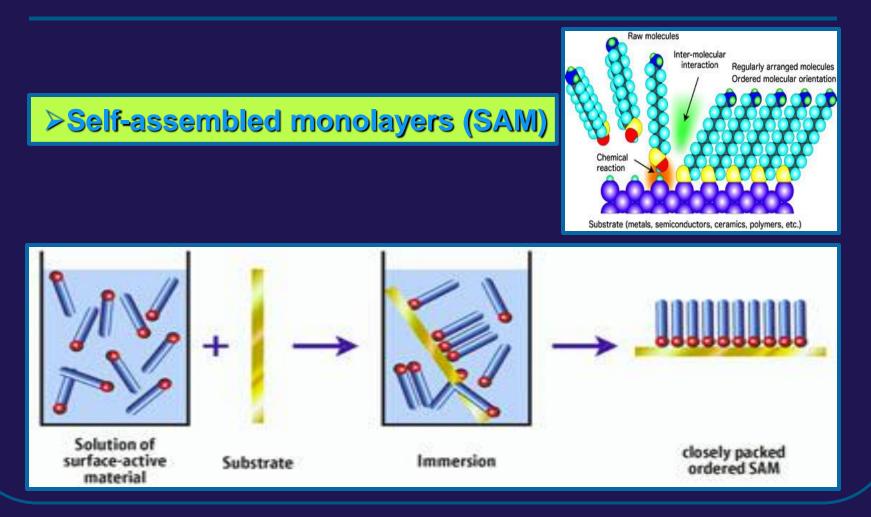








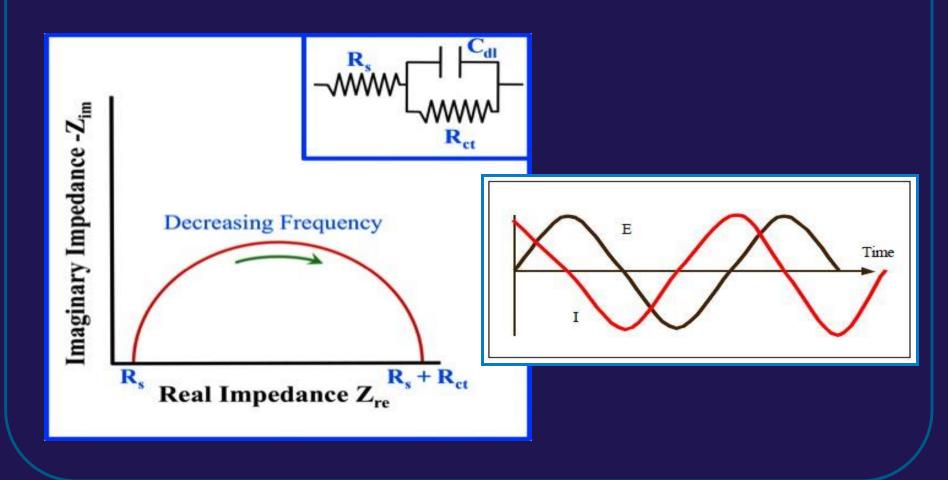
Introduction to the techniques

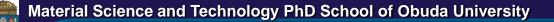


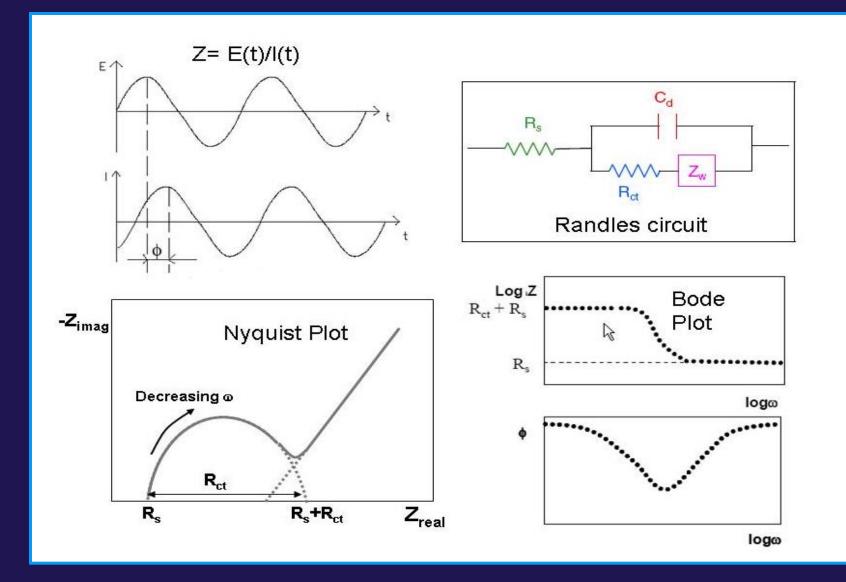
Representation of a SAM structure



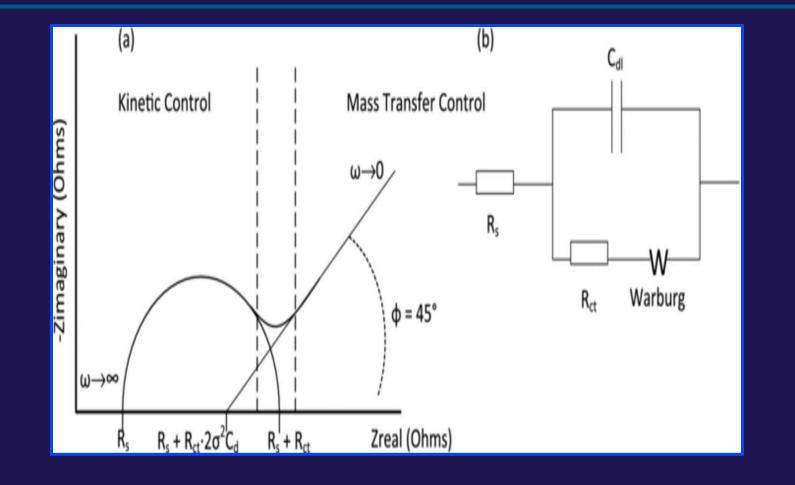
> Electrochemical Impedance Spectroscopy (EIS)













Reference Electrodes

Reference Electrode	Component Composition	vs (SHE) Volts	vs SCE Volts	vs Ag/AgCl [_] Volts	vs Cu/CuSO ₄ Volts
(SHE) Standard Hydrogen	(Pt) H ₂ /H+	•	-0.241	-0.25	-0.30
(SCE) Saturated Calomel Electrode	Hg/Hg ₂ Cl ₂ / sat KCl	+0.241	•	-0.009	-0.059
Silver/Silver Chloride (seawater)	Ag/AgCl/ 0.6 MCl⁻	+0.25	+0.009	•	-0.05
Copper/ Copper Sulphate	Cu/CuSO ₄ sat	+0.30	+0.059	+0.05	•

Conversion factors	(to convert add the value indicated)
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From E ¹	To SHE Scale	To SCE Scale
H ₂ /H ⁺ (SHE)		-0.241
Ag/AgCl sea water	+0.25	+0.047
Hg/Hg ₂ Cl ₂ /sat KCI (SCE)	+0.241	
Hg/Hg ₂ Cl ₂ /sat KCl (SCE)	+0.241	





Potentiodynamic curve (SI1287 SorItron/Electrochemical Interface(Potentiostat))

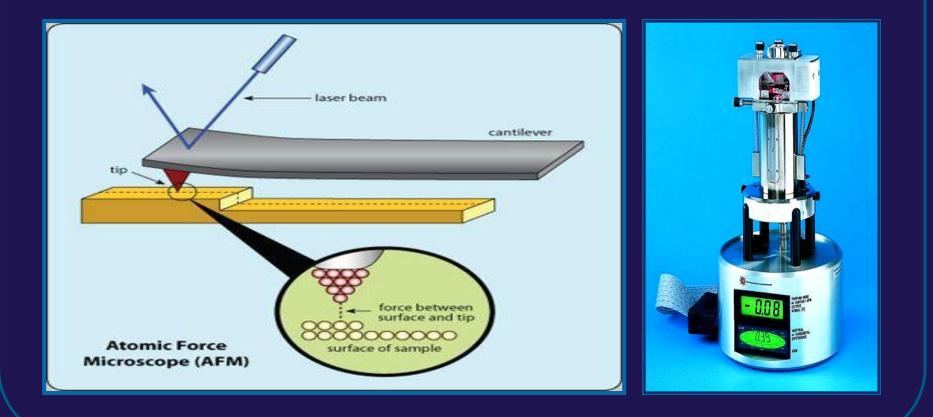


Electrochemical impedance spectroscopy (EIS) (SI 1260 Impedance/ Gain- Phase analyzer)



Surface morphology

>Atomic force microscopy (AFM)



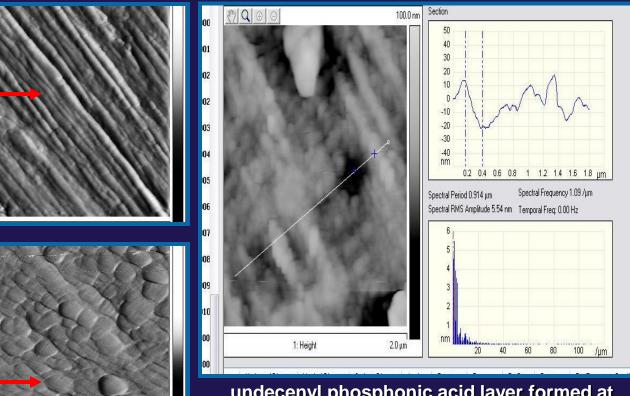








Udecenyl phosphonic acid

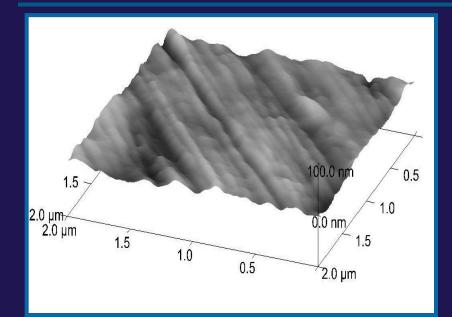


undecenyl phosphonic – acid layer formed at 30min

undecenyl phosphonic acid layer formed at 30min and treated with NaClO4 – for 2hrs.

undecenyl phosphonic acid layer formed at 30min and treated with NaCl for 2hr.

Fluorophosphonic acid



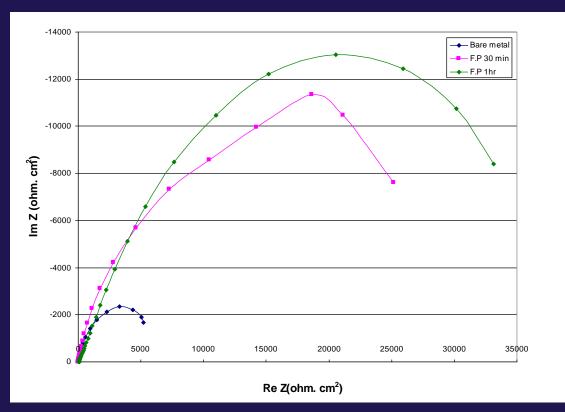
fluorophosphonic layer formed at 30min.

fluorophosphonic layer formed at 30min and treated with NaCl for 1hr.

She

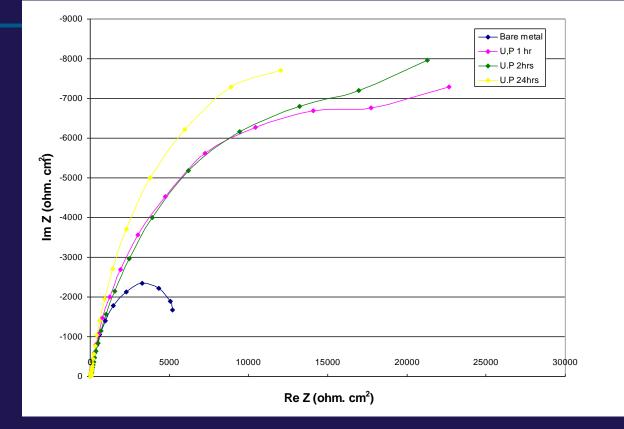
EIS result

>Effect of layer formation time



EIS measurements for fluorophosphonic acid layer at different formation time and tested in NaClO4 solution

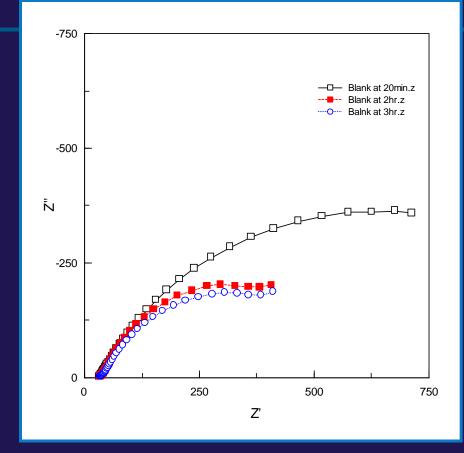




EIS measurements for undecenyl phosphonic acid layer at different formation time and tested in NaClO4 solution

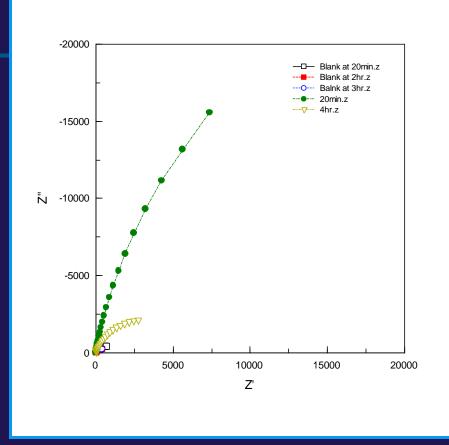


> Effect of time immersion in aggressive solution



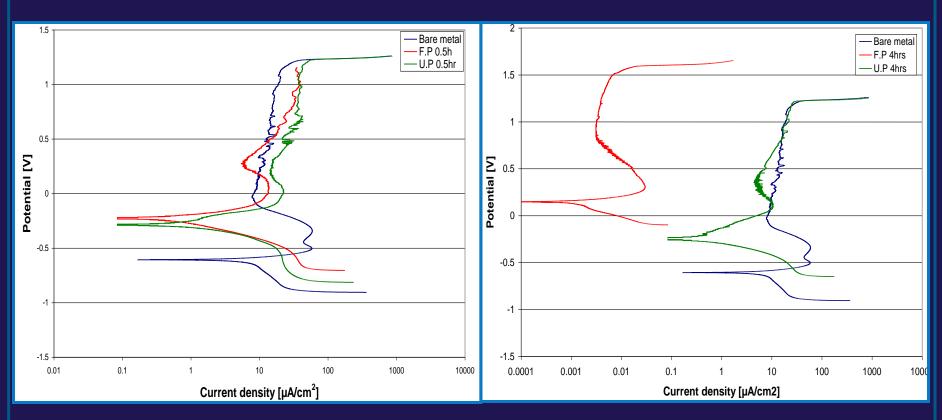
EIS measurements for fluorophosphonic acid layer (2hr) on carbon steel in NaClO₄ solution





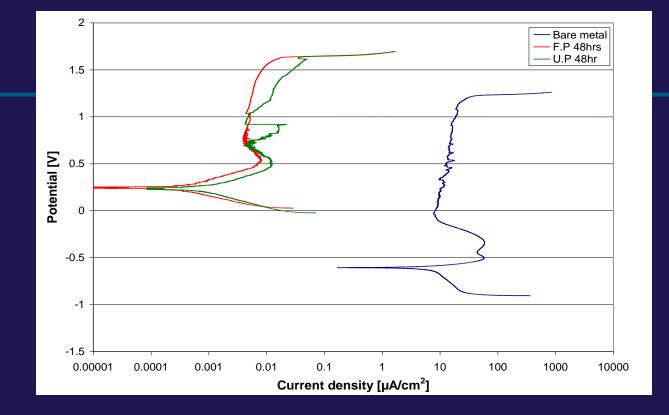
EIS measurements for undecenyl phosphonic acid layer (24hr) on carbon steel in NaClO₄ solution

Potentiodynamic results



Potentiodynamic polarization curves for layers formed at 30min with different chemicals (undecenyl and flourophosphonic acid) (NaClO4). Potentiodynamic polarization curves for layers formed at 4hrs with different chemicals (undecenyl and flourophosphonic acid) (NaClO4).





Potentiodynamic polarization curves for layers formed at 48hrs with different chemicals (undecenyl acid phosphonic and flourophosphonic acid) (NaClO4).







The EIS results show The undecenyl phosphonic acid and fluorophosphonic acid layers performed protection of the metal surface agains aggressive solution.



Potentiodynamic results showed that the undecenyl phosphonic acid and fluorophosphonic acid had the same performance for layers formed at 30min and 48 hrs although tre was a differnece with layers formed at 4hrs.



Undecenyl phosphonic acid resulted in excellent protective layers against corrosion although it decreased after 4hr.



In case of fluorophosphonic acid, increasing the layer formation time led to decreasing the corrosion rate.



AFM showed that the effect of sodium chloride was more savior than that of sodium perchloride where pitting corrosion occurred.



